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Jefferson Lab

Precise timing with PICOSEC μ RWELL & Micromegas detector

(On behalf of PICOSEC collaboration)

Akash Pandey

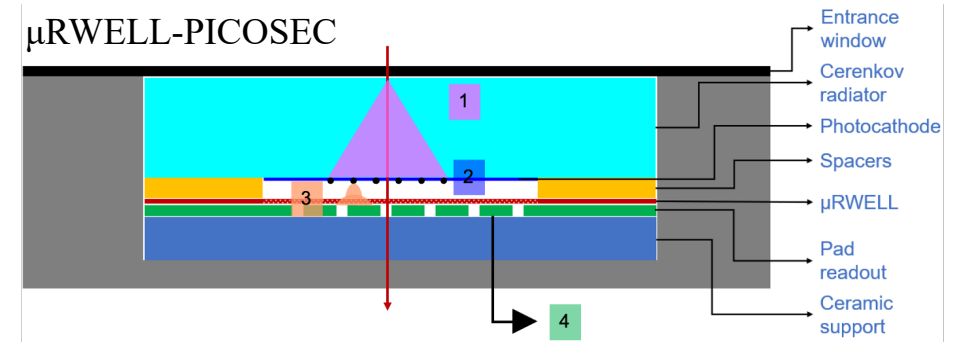
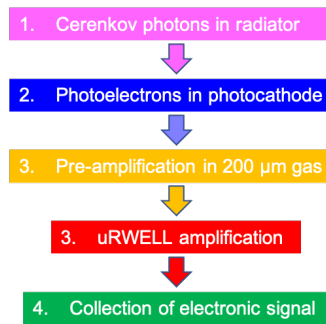
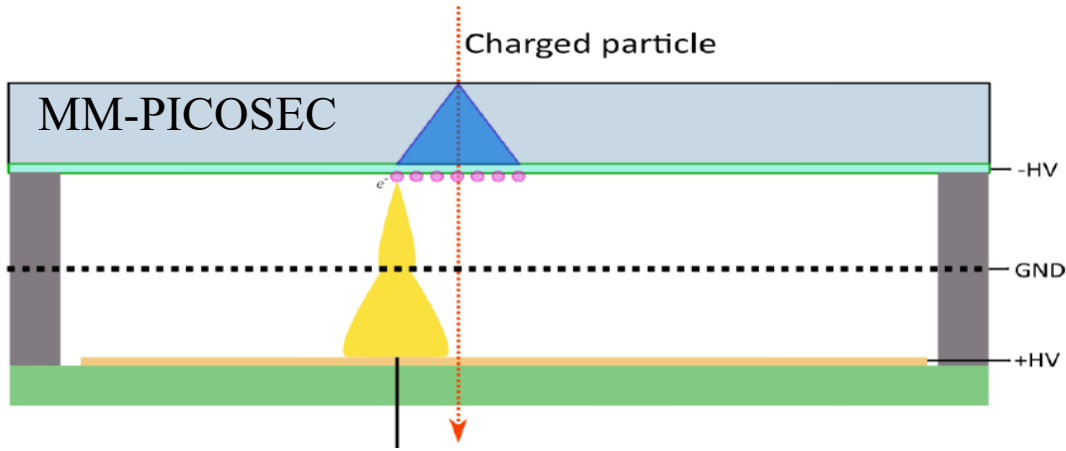
Radiation Detectors & Imaging Group (RD&I Group), Jefferson Lab

Outline

- **Detection concept of μ RWELL & Micromegas PICOSEC**
- **Test beam setup**
- **Preliminary results from Test beam-2023** (Single channel μ RWELL- PICOSEC prototype)
- **Preliminary results from Test beam-April 2024** (New housing & design of single channel μ RWELL- PICOSEC prototype)
- **Plan for Test beam-July 2024**
- **Updates from PICOSEC Micromegas**
- **Summary**

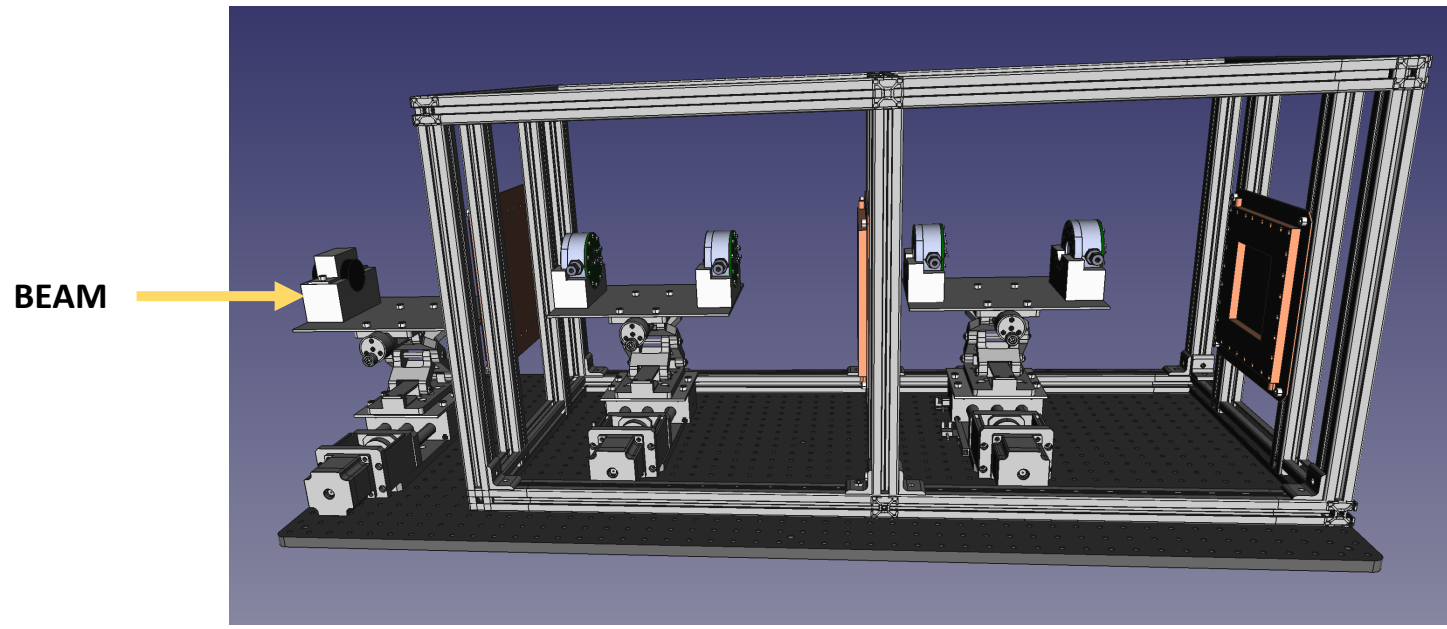
Working principle

- Cherenkov photons:** relativistic charged particle creates Cherenkov photons → prompt photons i.e., timing resolution.
- Photoelectrons:** convert the Cherenkov photons into electrons, all electrons created at the same z position → timing resolution
- Pre-amplification:** First amplification of electrons 100 to 200 μm gas in high drift field region ($\sim 20 \text{ kV/cm}$)
- Amplification:** Final electron amplification in μRWELL gain structure → high electric field ($>40 \text{ kV/cm}$)
- Electronic Signal:** Arrival of the amplified electrons to the anode creates a signal.

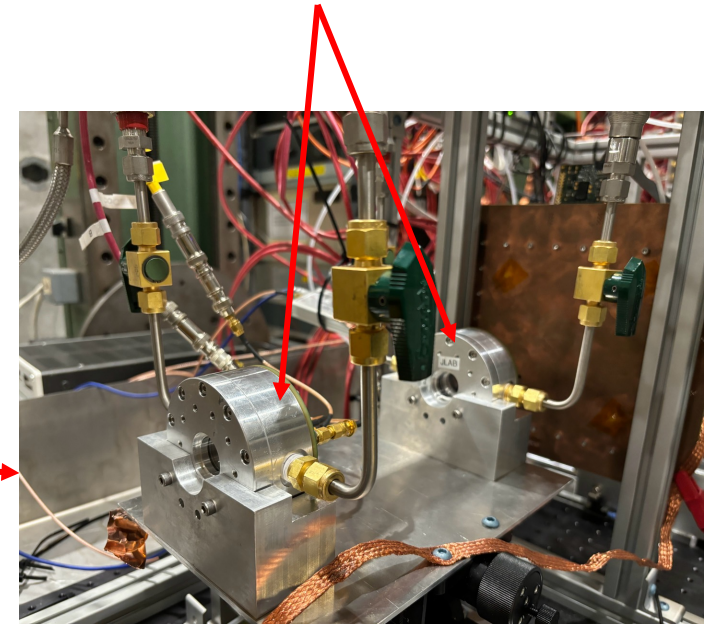
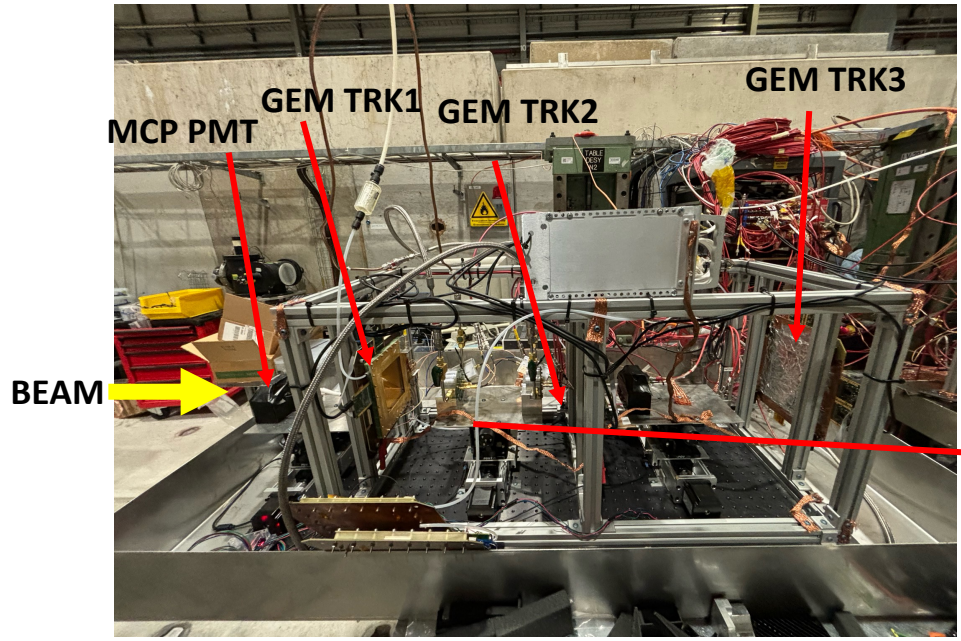


	MM-PICOSEC	$\mu\text{RWELL-PICOSEC}$
Radiator / photocathode	Both technologies share the same devices	Both technologies share the same devices
Readout structure	Both technologies share the same devices	Both technologies share the same devices
Amplification structure	mesh → 128 μm gap	Cu-clad Kapton foil → 50 μm gap
Resistive vs. metallic	Both options available	Only resistive
Segmentation MPGD	Segmentation of the mesh will be challenging	μRWELL Cu-electrode can be segmented

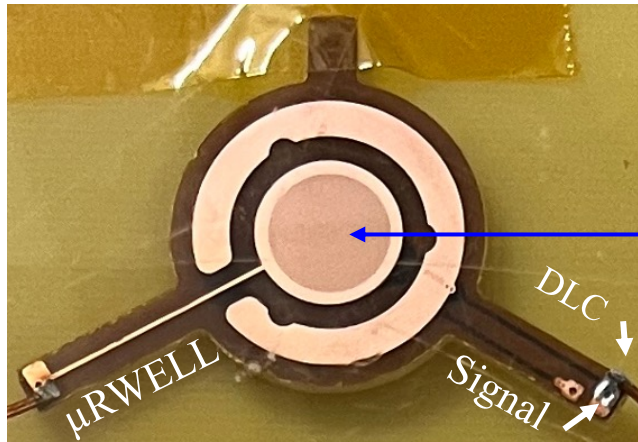
Test beam setup of single channel single channel μ RWELL-PICOSEC



Single channel μ RWELL PICOSEC prototypes



Single channel μ RWELL prototypes (Test beam-2023)



μ RWELL-PICOSEC prototype

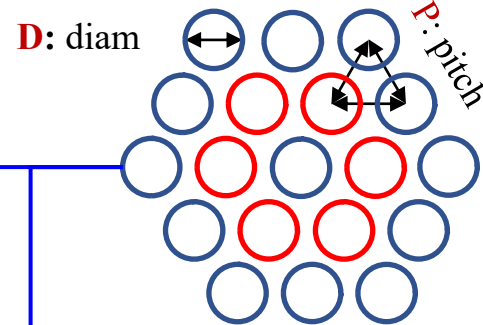
Nomenclature of the prototypes:

T150-**P**140-**D**70

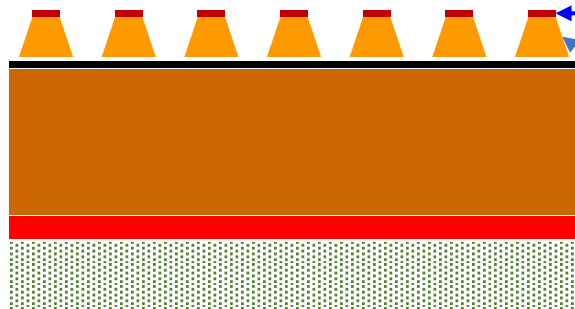
T = 150 μm \rightarrow Kapton thickness

P = 140 μm \rightarrow Hole pitch

D = 70 μm \rightarrow Hole Outer Diam.



hole geometry



Cross section view of μ RWELL-PICOSEC PCB

uRWELL foil

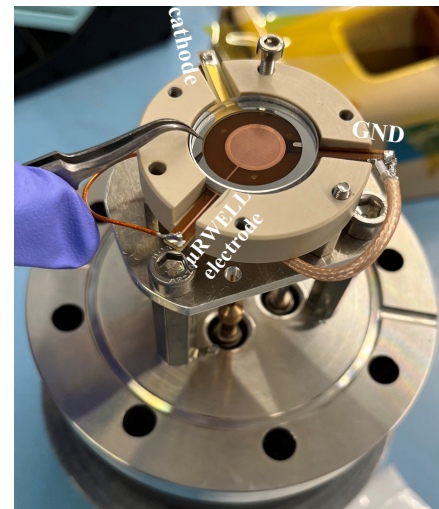
DLC layer

Kapton

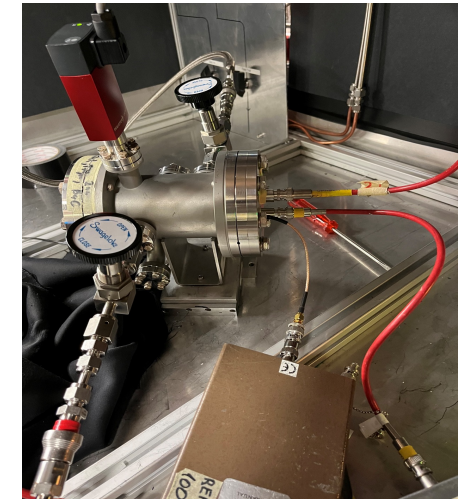
Pad electrode

PCB support

batch	Prototype	T (μm)	P (μm)	D (μm)	d (μm)
I	T50-P140-D70	50	140	70	50
II	T 150 -P140-D70	150	140	70	50
II	T 150 -P140-D85	150	140	85	65
II	T 150 -P140-D70	150	120	70	50
II	T 150 -P140-D85	150	120	85	65

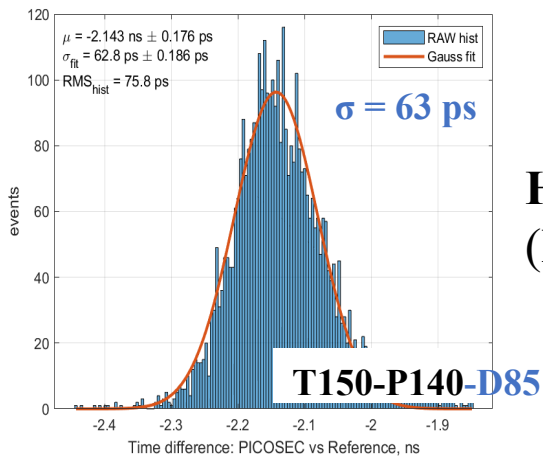
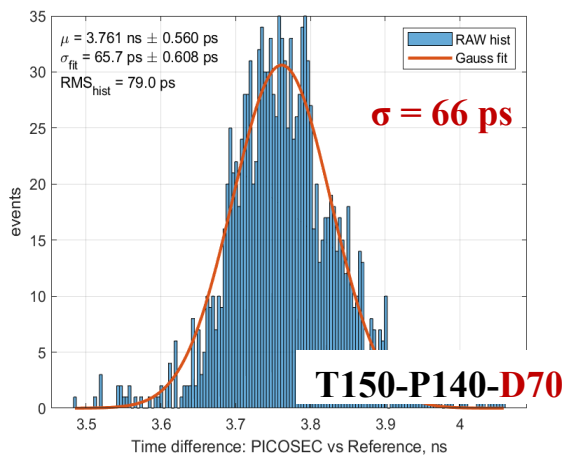


Single-pad μ RWELL-PICOSEC prototype

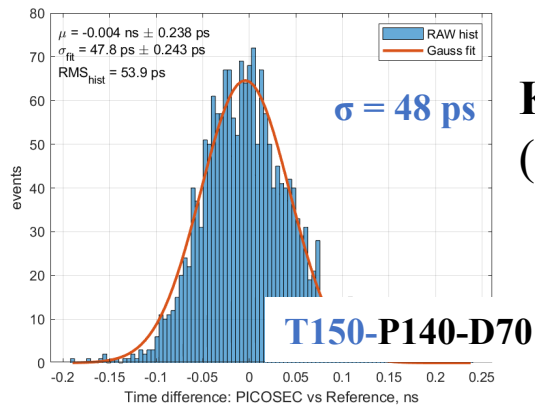
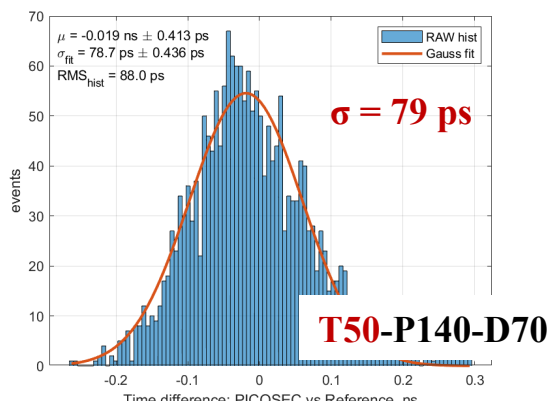


Prototype on test bench at CERN GDD Lab

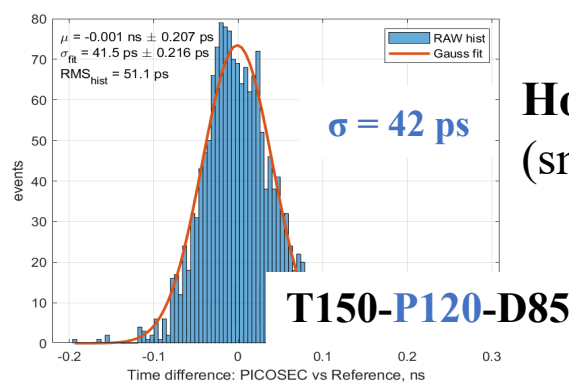
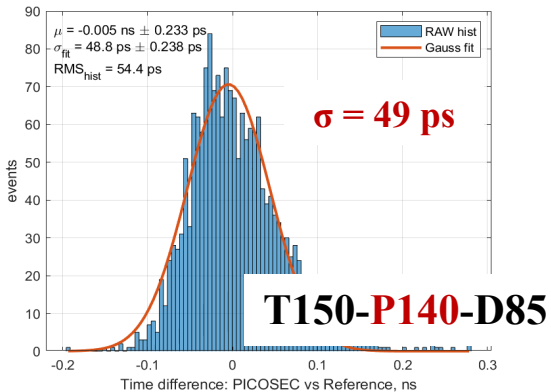
Preliminary results (Test beam-2023)



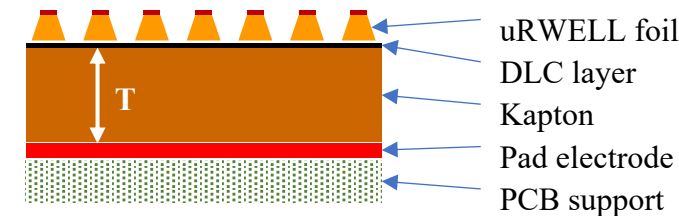
Hole diameter comparison
(Larger holes for same pitch \rightarrow better timing)



Kapton thickness comparison
(Thicker Kapton \rightarrow better timing)



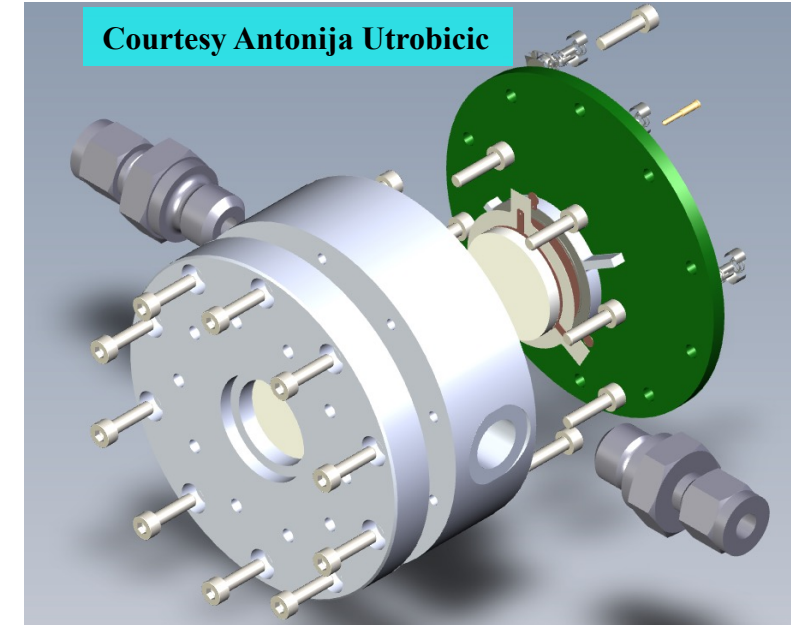
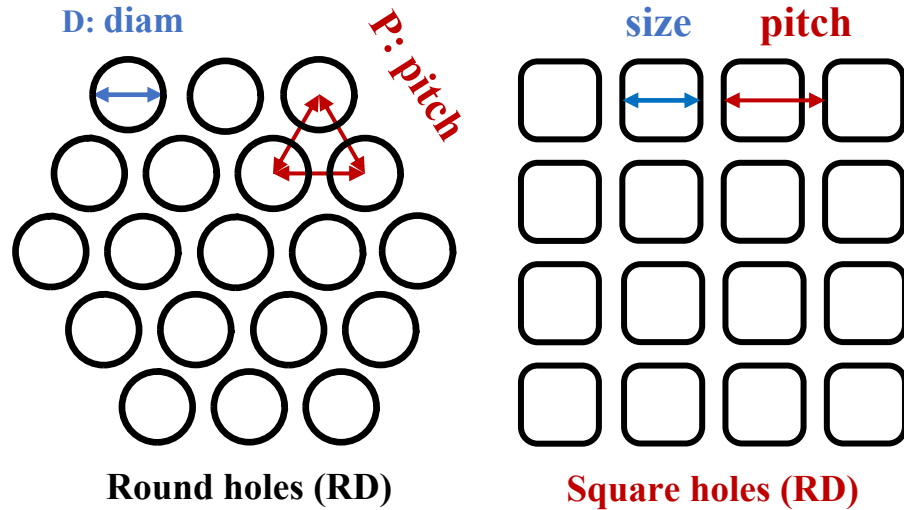
Hole pitch comparison
(smaller pitch \rightarrow better timing)



Cross section view of μ RWELL-PICOSEC PCB

New mechanical housing and design of single channel μ RWELL-PICOSEC (Test beam-April 2024)

New hole geometries



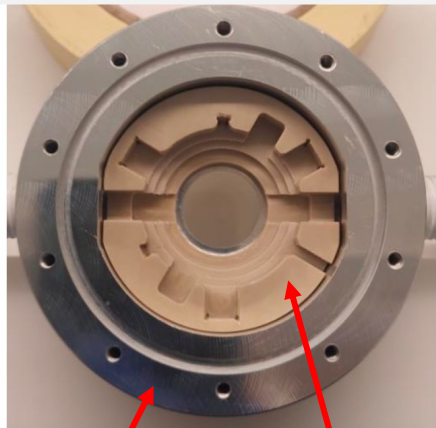
New mechanical housing

- ❖ Minimize external source of noise (i.e. grounding, cables pick-up antenna ...)
- ❖ Makes it easier to quickly exchange prototypes (replacement of μ RWELL-PCBs, photocathodes) during beam test

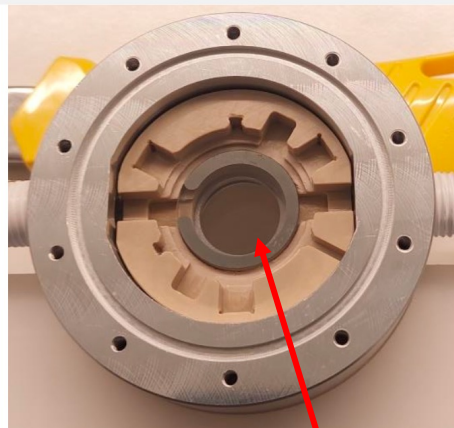
Prototype	Shape	P	D	d
SQ-T150-P120-D100	square	120	100	80
RD-T150-P120-D100	round	120	100	80
RD-T150-P100-D80	round	100	80	60
RD-T150-P80-D60	round	80	60	40

New mechanical housing of single channel μ RWELL-PICOSEC (April Test beam 2024)

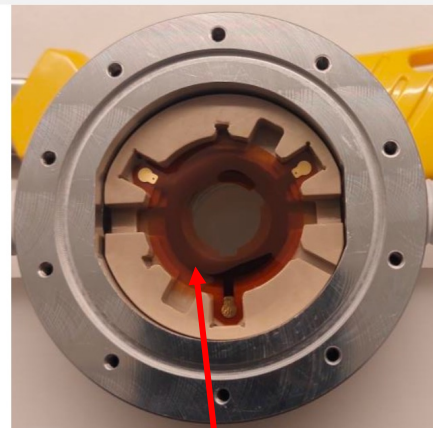
Courtesy Antonija Utrobicic



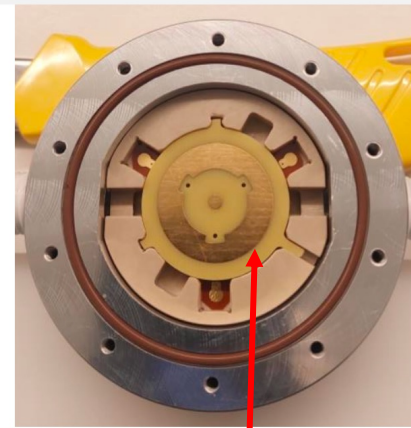
Al chamber



PEEK insert



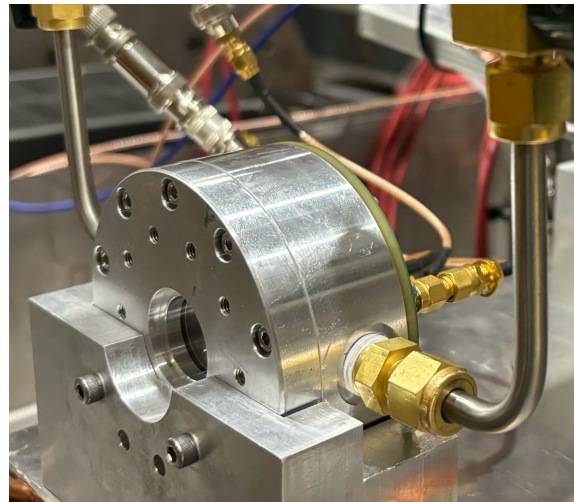
MgF₂



μ RWELL PCB



Outer board



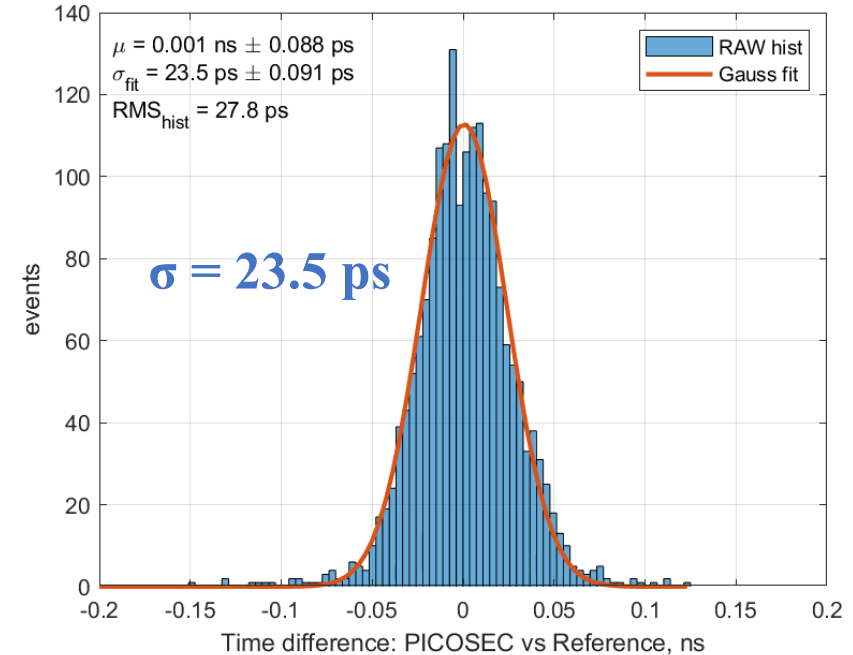
Our μ RWELL prototype in the housing

We have tested the following combinations of single channel μ RWELL-PICOSEC prototypes:

1. μ RWELL7 (CsI batch 2), Round P:120 H(o):100 H(i):80, Spacer: 170 μ m, Readout: Grided
 μ RWELL5 (CsI batch 4), Round P:120 H(o):100 H(i):80, Spacer: 170 μ m, Readout: Plain
2. μ RWELL9 (CsI batch 2), Round P:100 H(o):80 H(i):60, Spacer 170 μ m, Readout: Plain
 μ RWELL11 (CsI batch 4), Round P:100 H(o):80 H(i):60, Spacer 170 μ m, Readout: Grided
3. μ RWELL1 (CsI batch 4), Square P:120 H(o):100 H(i):80, Spacer 170 μ m, Readout: Plain
 μ RWELL3 (CsI batch 4), Square P:120 H(o):100 H(i):80, Spacer 170 μ m, Readout: Grided
4. μ RWELL5 (CsI batch 4), Round P:120 H(o):100 H(i):80, **Spacer 120 μ m**, Readout: Plain
 μ RWELL9 (CsI batch 4), Round P:100 H(o):80 H(i):60, **Spacer 120 μ m**, Readout: Plain
5. μ RWELL13 (CsI batch 4), Square P:80 H(o):60 H(i):40, Spacer 170 μ m, Readout: Plain
 μ RWELL9 (CsI batch 4), Round P:100 H(o):80 H(i):60, **Spacer 120 μ m**, Readout: Plain

Preliminary results (Test beam-April 2024)

- Fused silica window, MgF₂ as crystal and CsI photo cathode
- Gas mixture of Neon: C₂H₆ : CF₄ = 80: 10:10
- The result has been obtained for the prototype with 120 μm pitch, 100 μm OD and 80 μm ID and plain pad



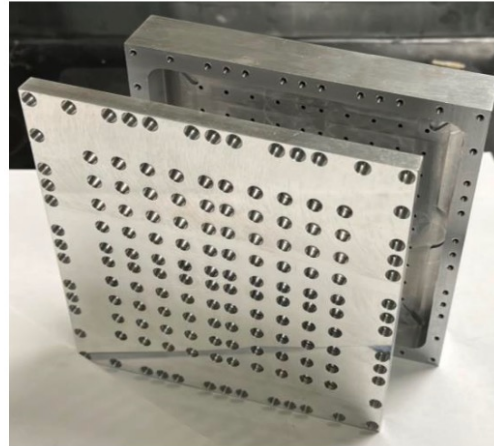
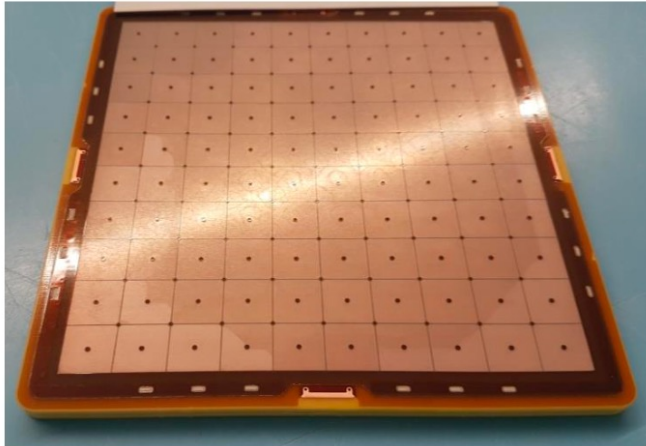
Time resolution of single channel μRWELL- PICOSEC with 170 μm preamplification gap.

Timing resolution gets improved (~23 ps) with new mechanical housing & design of single channel μRWELL- PICOSEC

Plans for Test beam-July 2024

Testing of Large-area (10 cm × 10 cm) μ RWELL-PICOSEC prototype with 100-pads readout

Large 100-pad prototypes (Micromegas & μ RWELL)



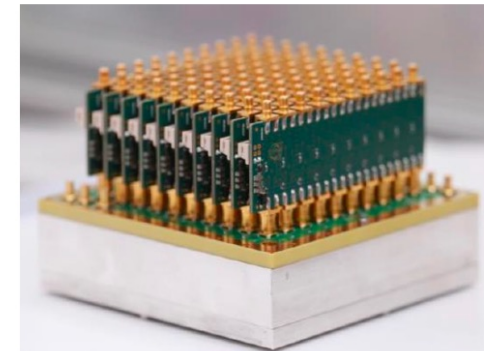
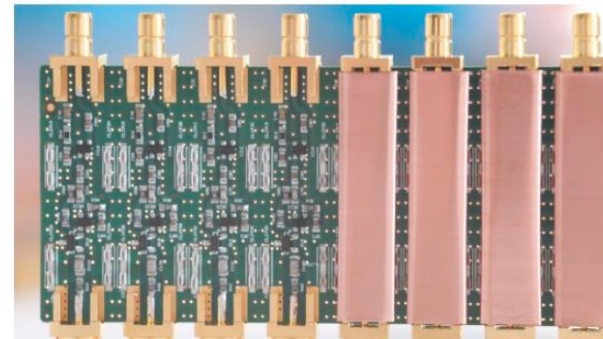
- ❖ 100-pad μ RWELL-PICOSEC & MM-PICOSEC prototypes
- ❖ Parameters based on single-channel prototypes studies
- ❖ Mechanical housing fabricated in the JLab machine shop
- ❖ Same housing for MM-PICOSEC & μ RWELL-PICOSEC
- ❖ Multi-channel readout PCB interface board under development
- ❖ MM-PICOSEC used as reference detector
- ❖ Large prototypes will be tested in beam at CERN in FY24

Multi channel digitizer SAMPIC (D. Breton, CEA Saclay)



https://indico.cern.ch/event/396441/contributions/1836629/attachments/794757/1089389/02_SAMPIC_Prague.pdf

Multi-channel custom-made pre-amplifier (M. Kovacic, U. of Zagreb)



Updates from PICOSEC Micromegas

Precise timing with PICOSEC Micromegas

Resistive Micromegas

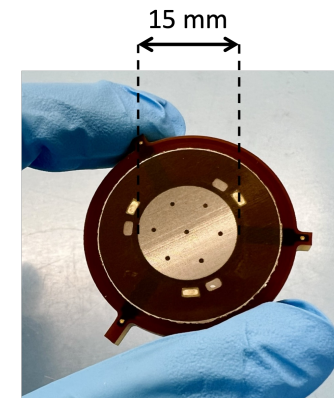
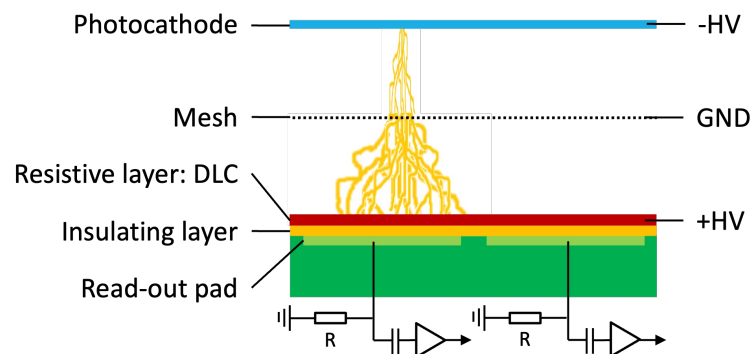
- **Advantages:**

- + protecting detector from highly ionizing events
- + ensuring stable operation under intense particle beams
- + achieving better position reconstruction by signal sharing

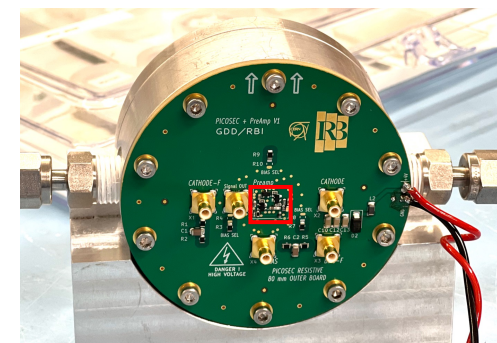
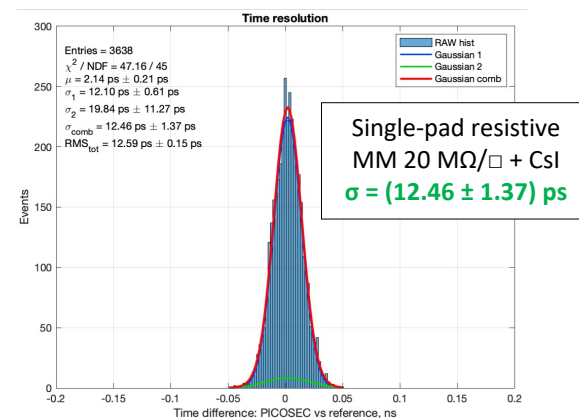
- **Single-pad resistive MM of 20 M Ω /□** equipped with a CsI photocathode obtained equivalent precision to a non-resistive prototype, exhibiting **an excellent time resolution of $\sigma \approx 12$ ps**

- Single-pad resistive MM assembled with **a preamplifier integrated on the outer PCB** showed comparable timing properties

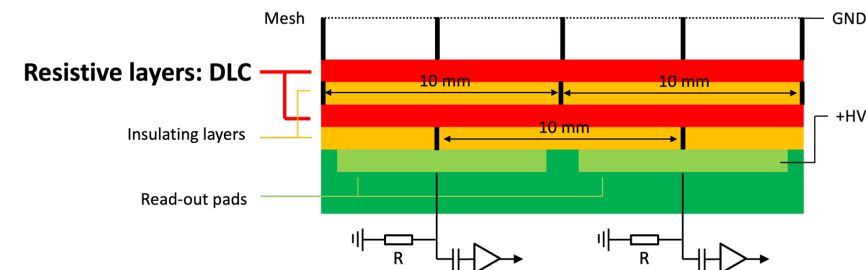
- **Next step:** production of a high-rate 10×10 cm² MM with double-layer DLC for vertical charge evacuation and evaluation of rate capability



Resistive single-pad prototype



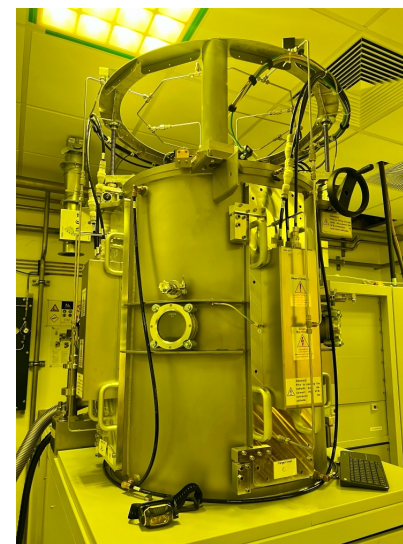
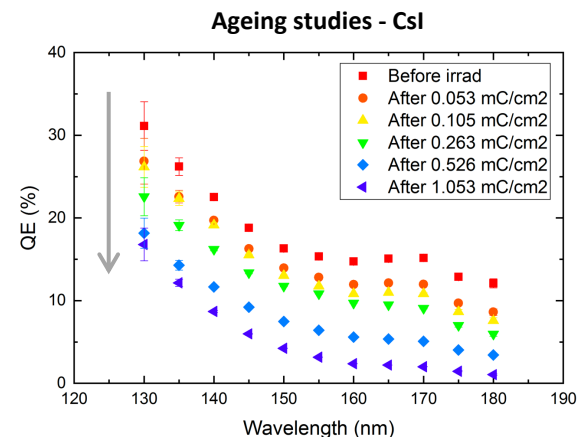
Amplifier integrated on the outer PCB



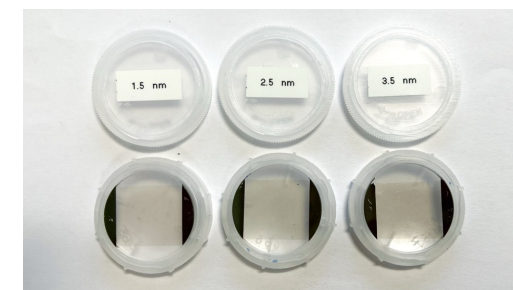
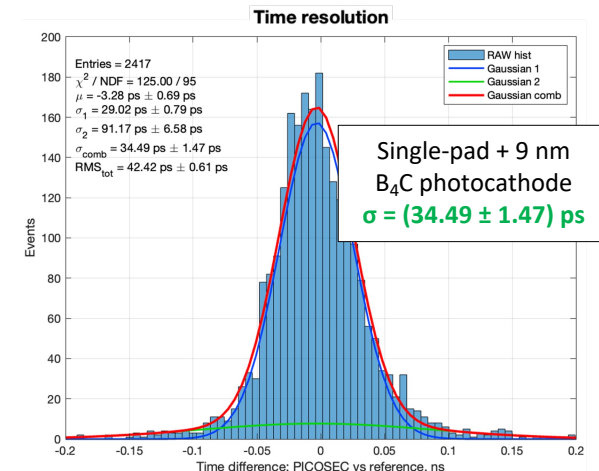
Precise timing with PICOSEC Micromegas

Robust photocathodes

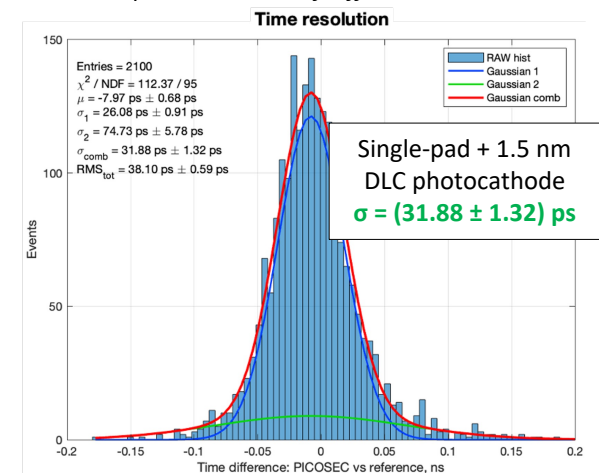
- First single-pad prototype: Cesium Iodide
 - + high QE (~ 12 p.e./ μ) in comparison to other materials
 - vulnerable to damage from ion backflow, discharges and humidity
- **Alternative photocathodes:** B₄C, DLC, carbon-based nanostructures
- Previous measurements conducted with B₄C photocathodes exhibited the best time resolution of $\sigma \approx 34.5$ ps for the 9 nm layer
- **First depositions of DLC photocathodes carried out at the CERN MPT workshop** using a magnetron sputtering technique
- The best results for a single-pad detector achieved with a **1.5 nm DLC photocathode**, yielding a **time resolution of $\sigma \approx 32$ ps**
- **Next step:** evaluation of a 10×10 cm² robust photocathode



Pulsed DC magnetron vacuum deposition machine



DLC photocathodes of different thicknesses



Gas studies

Standard mixture:

Neon / ethane (C_2H_6) / CF_4 90% /10% /10%

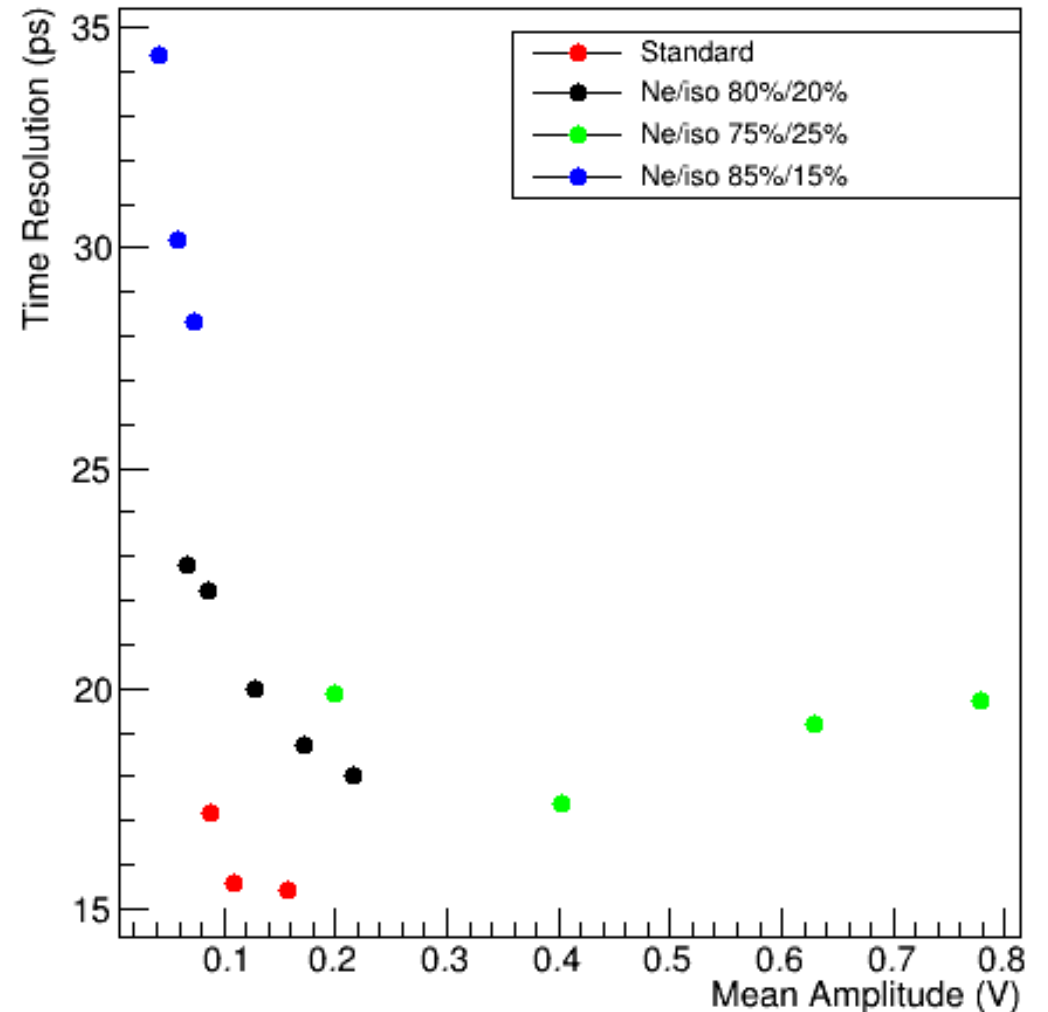
- Expensive
- Flammable
- High GWP (~ 740)

New mixtures:

Neon / Isobutane (iC_4H_{10}) different ratios

Preliminary results:

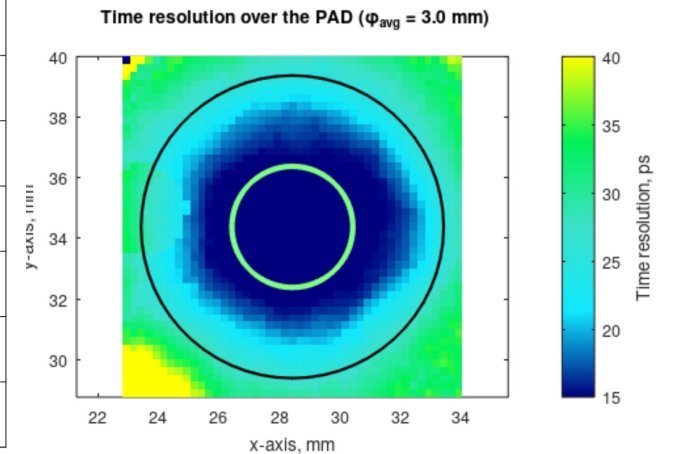
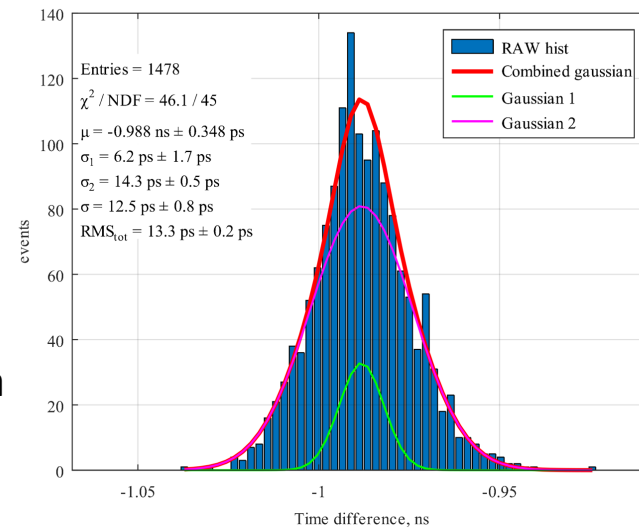
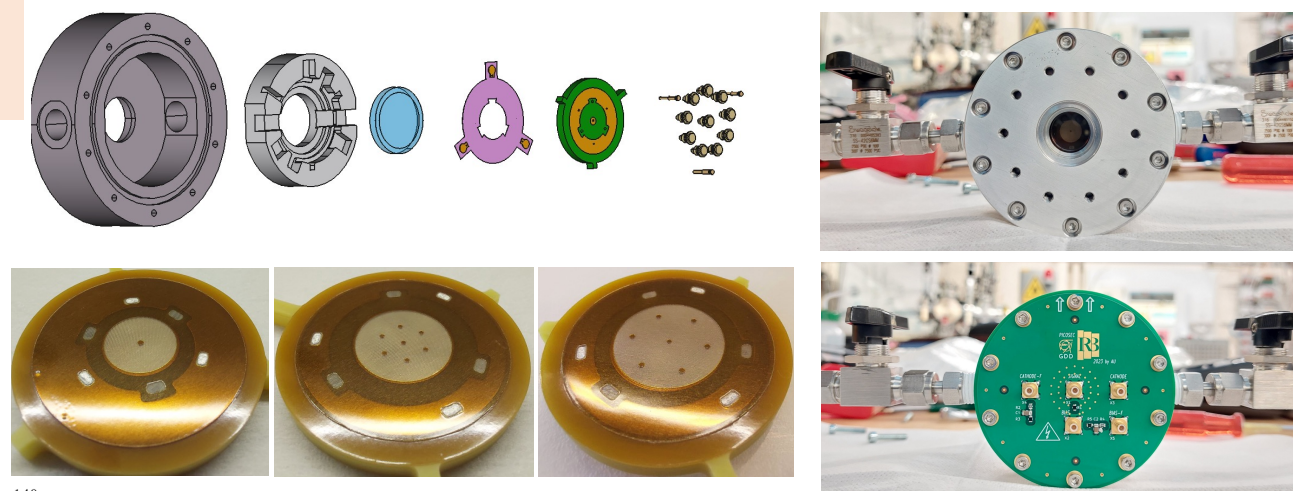
- Reached ~ 17 ps with the 75/25 mixture and ~ 19 with the 80/20 (~ 15 ps with the standard mixture)
- Need to determine precisely the concentration inside the detector due to problems with the gas mixing system
- Ne/iso mixture good candidates to achieve good time resolution with low GWP (order of 1)



Voltage scan performed with different gas mixtures. Detector with non-resistive micromegas and CsI photocathode. The last point of every curve is the one obtained with the highest achievable gain.

New single channel PICOSEC Micromegas (MM) detector

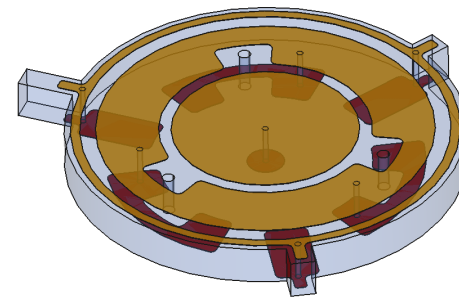
- The new detector housing and three different size of MM boards with 10 mm, 13 mm and 15 mm diameter active area that are compatible with same housing were designed and produced.
- Focus on improving stability, reducing noise, ensuring signal integrity and uniform time response over entire active area.
- Fast assembly procedure: quick and easy replacement of detector elements.
- Successfully commissioned with MIP at SPS H4 beamline. Test beam results showed that all three prototypes can operate stable with very uniform time response.
- The 10 mm detector achieved an outstanding time resolution of **12.5 ps**, while larger detectors followed with a resolution at a level of 18 ps in the central pad region (MCP jitter not subtracted).



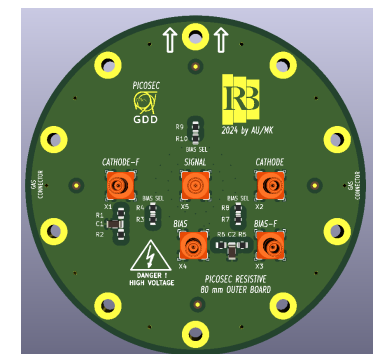
Ongoing and planned activities:

- Development of a resistive MM prototype with 10 mm and 15 mm diameter active area (first beam tests with 150 GeV/c muons done in April 2024.).
- Preamplifier integration to the detector housing.
- System level optimization of the detector, amplifier and digitizer.

Slide reference: Antonija Utrobicic (antonija.utrobicic@cern.ch)

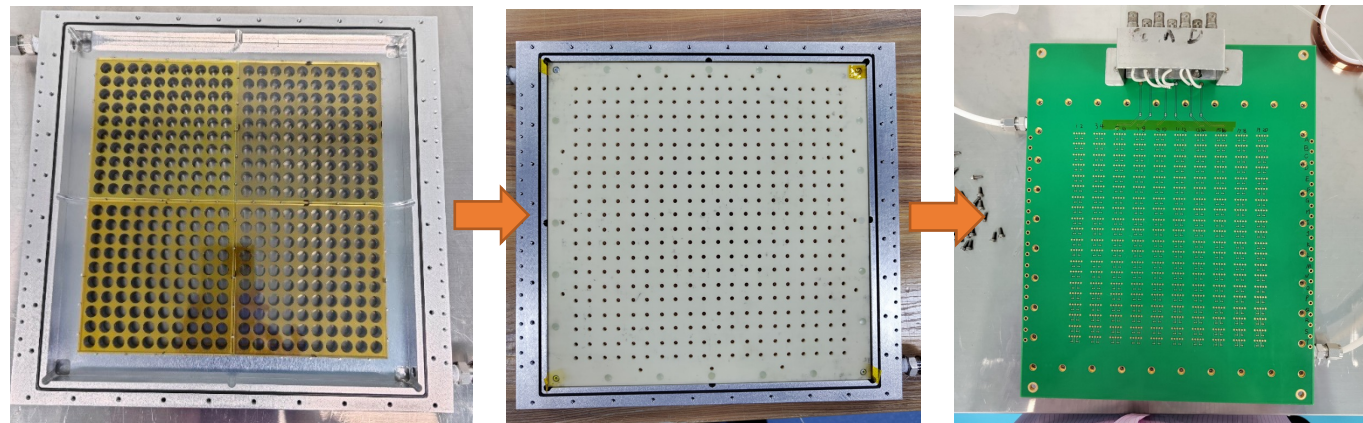
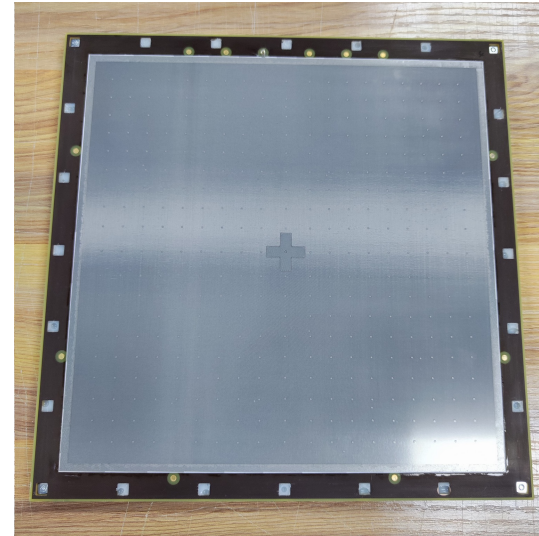
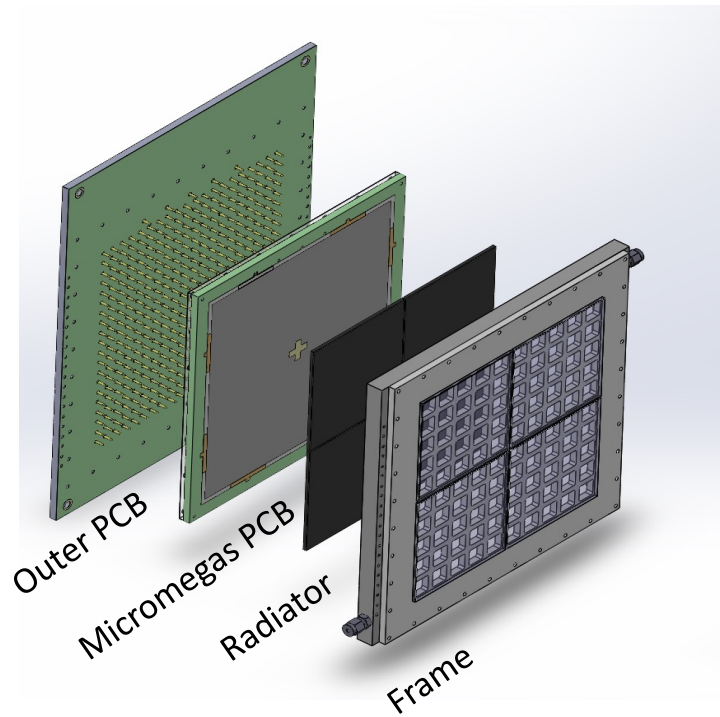


Resistive MM detector substrate layout



Resistive detector Outer board design

Large Area 20*20 PICOSEC

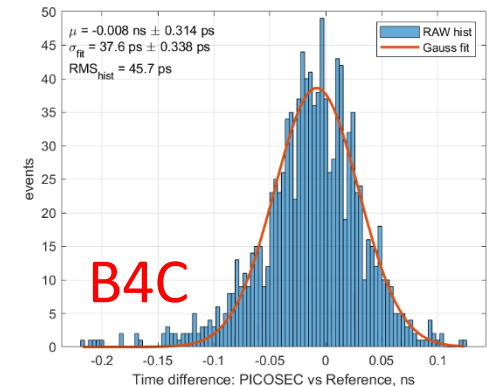
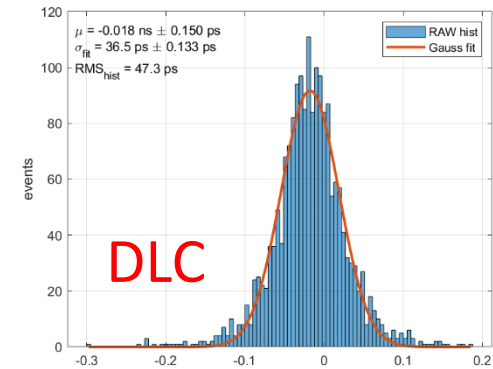
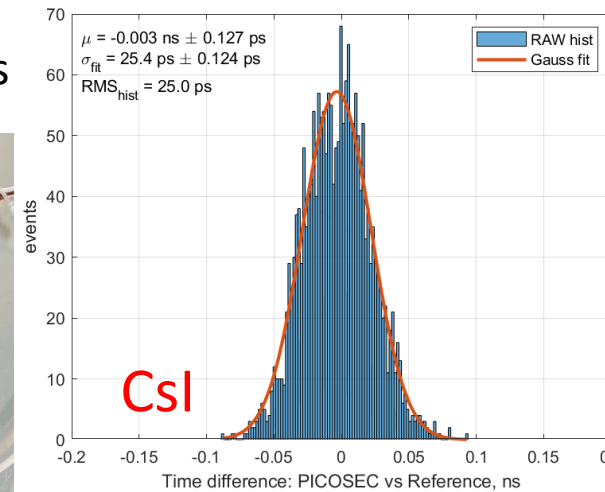


First 20*20 PICOSEC Micromegas:

- 400 pads on 200mm*200mm Micromegas
- resistive micromegas by thermobonding method
- Joint of four 104*104mm MgF2
- Four photocathodes applying HV independent

Preliminary Beam Test Results (Beamtest April 2024):

- Tested 3 different photocathodes with different pads
- Best timing from CsI is **25.4ps** (510/270)
- DLC with 36.5ps (690/260)
- B4C (Boron Carbide) with 37.6ps (660/260)



JLab group PICOSEC members

Kondo Gnanvo,

Brian Kross,

Jack McKisson,

Drew Weisenberger,

Wenze Xi

Summary

- In the April 2024 test beam at CERN, several combinations of the well's pitch, outer diameter, and inner diameter have been tested with new mechanical housing of single channel μ RWELL-PICOSEC prototype .
- Different types of well shapes, including square and round, as well as plain and strip readout pads, have been also investigated for the single channel μ RWELL-PICOSEC prototypes.
- More than 60 runs of 50k event each has been taken in April 2024 test beam → analysis ongoing
- A time resolution of 23.7 ps has been achieved with the new housing and new geometry of single channel μ RWELL-PICOSEC prototype having round shaped hole with 120 μ m pitch, 100 μ m as outer diameter, 80 μ m as inner diameter and 170 μ m as a preamplification gap.

The research described in these slides was conducted under the Laboratory Directed Research and Development (LDRD) Program at Thomas Jefferson National Accelerator Facility for the U.S. Department of Energy



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Backup

Applications of μ RWELL- PICOSEC detector

- Develop fast, precise, and cost-effective gaseous detectors for particle physics and medical applications with properties like stability, radiation hardness, large area coverage, and segmented readout capabilities.
- The MM-PICOSEC collaboration has proven the concept using Micromegas technology, and picosecond detectors based on μ RWELL technology show great potential.
- μ RWELL-PICOSEC technology offers promising alternatives for PID systems, TOF detectors for charged particles, and Cerenkov photosensor technologies.
- Potential applications include future projects like the Electron Ion Collider (EIC) Detector II, the ePIC upgrade, future experiments at Jefferson Lab, and medical instrumentation such as TOF-PET devices.

μ RWELL-PICOSEC: Amplification structure

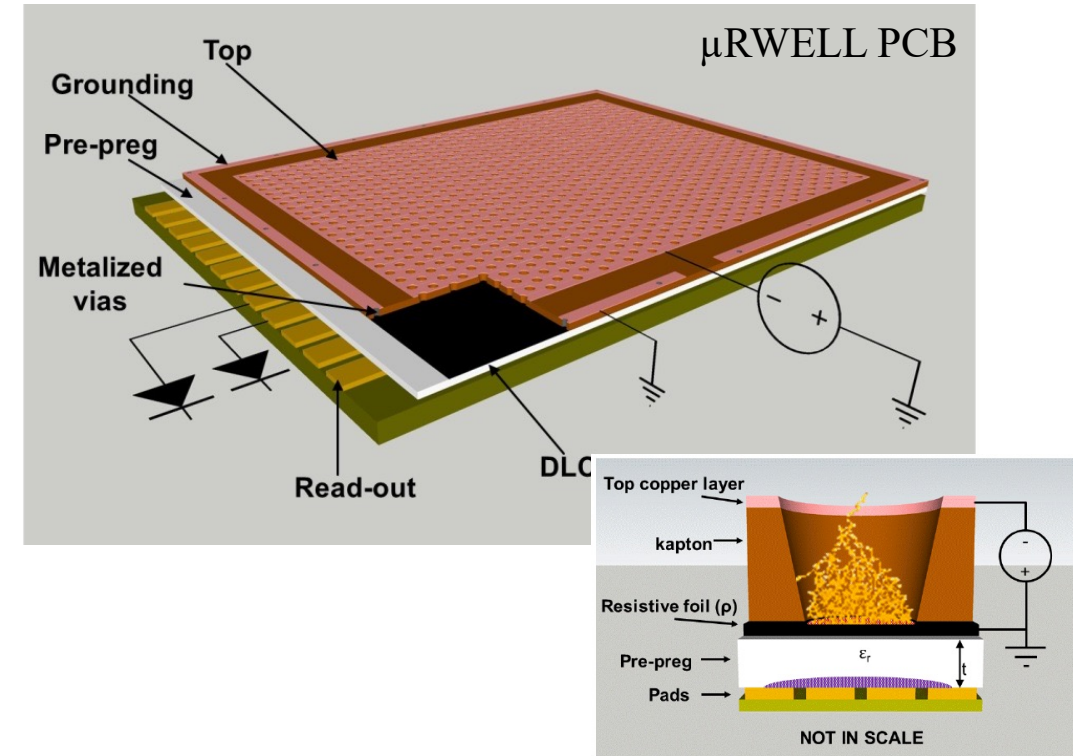
Design of μ RWELL foil

- ❖ Single layer amplification MPGD
 - Simple amplification structure using same material as GEM foil
 - Resistive technology \rightarrow intrinsically robust against spark
 - Large area capability
- ❖ Specially well suited for PICOSEC technology
 - μ RWELL is a resistive MPGD \rightarrow improve detector stability & backup
 - Segmented μ RWELL (PEP) \rightarrow improve rate capability & timing

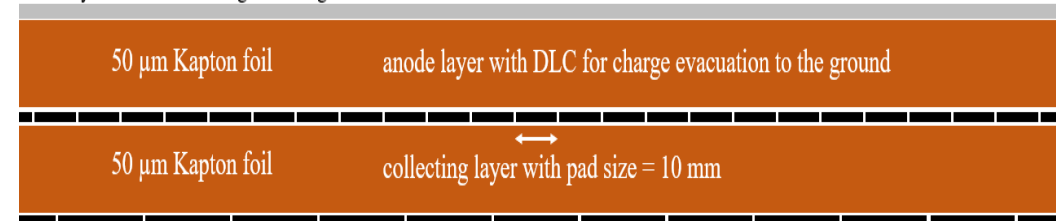
Integration of capacitive-sharing readout structures

- ❖ Capacitive-sharing pad readout will allow precise position information capability with limited readout channel number
- ❖ Combining segmented μ RWELL and capacitive-sharing \rightarrow best of both world
 - Segmented μ RWELL: excellent timing resolution
 - Capacitive-sharing readout: excellent position resolution

[G. Bencivenni et al 2015 JINST 10 P02008](#)



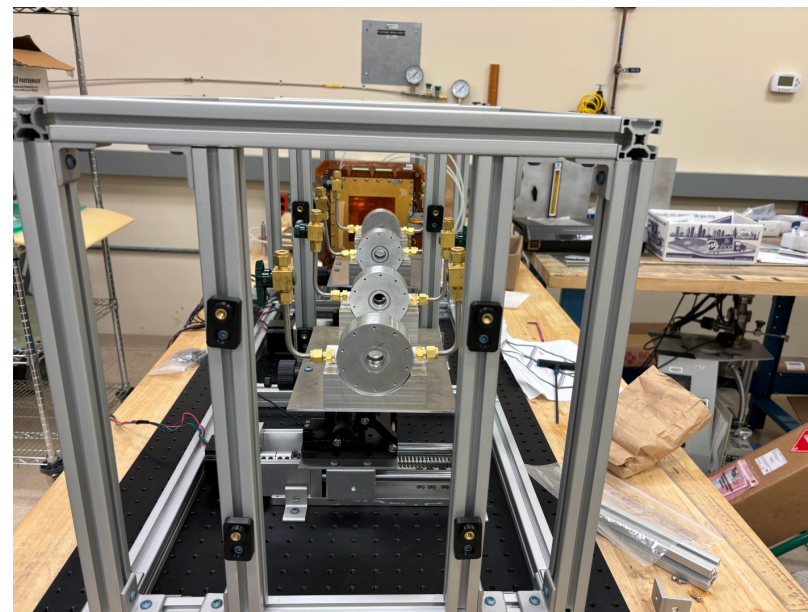
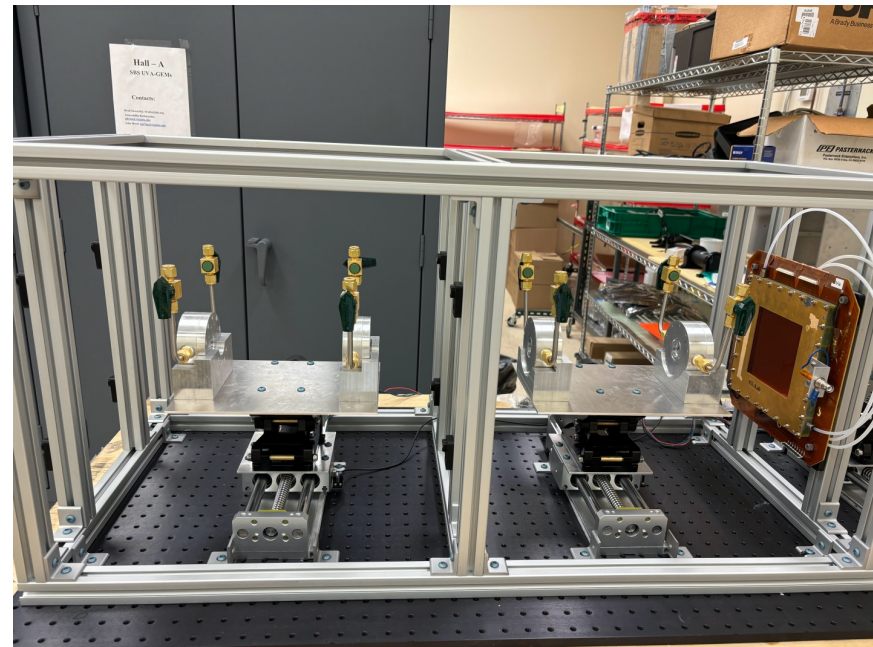
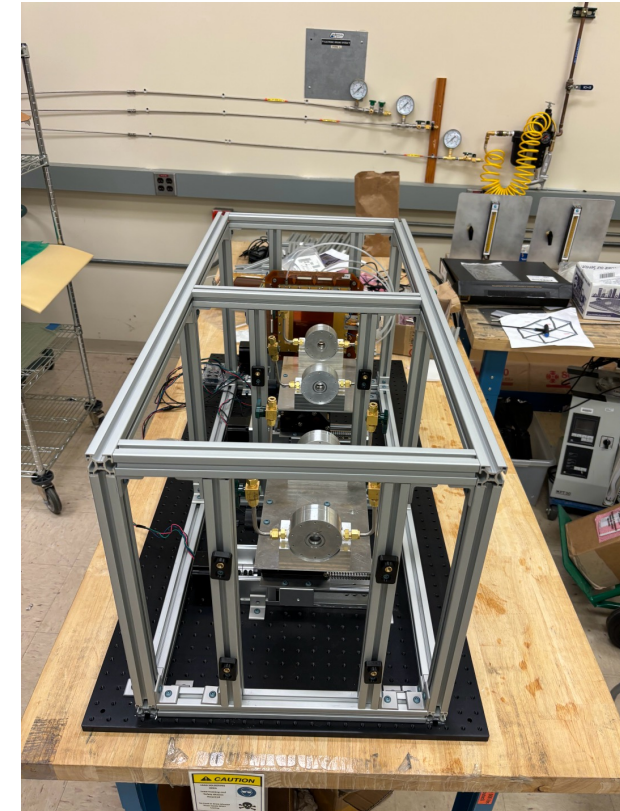
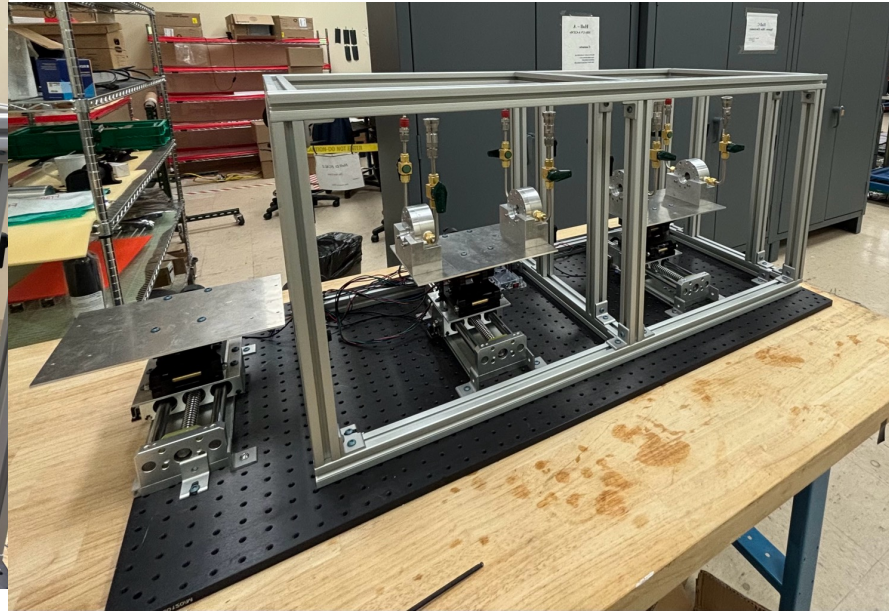
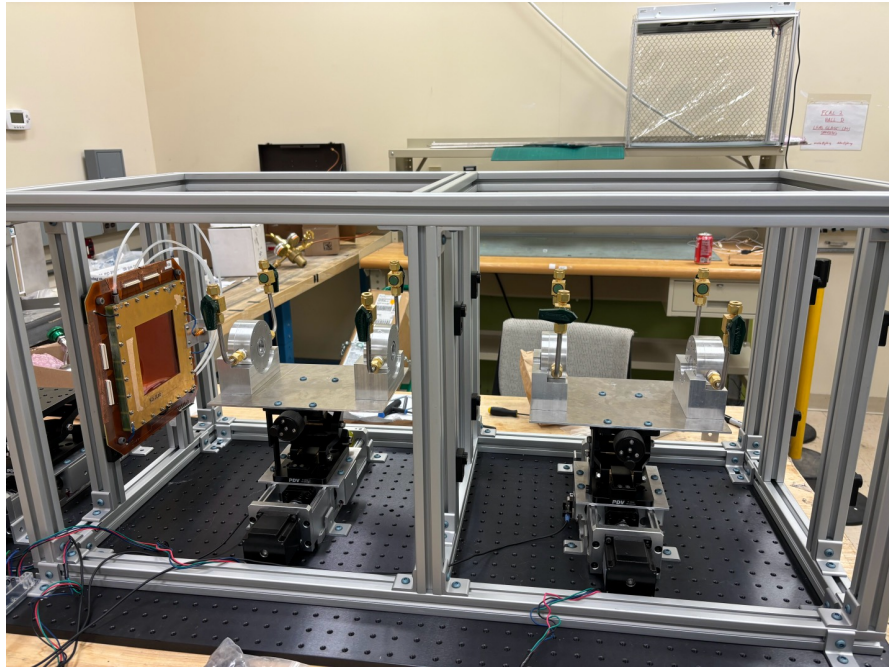
DLC layer to evacuate charges to the ground



Concept capacitive-sharing pad readout

[K. Gnanvo et al., NIM A, 1047 \(2023\) 167782](#)

Assembly of μ RWELL-PICOSEC telescope at JLab



μ RWELL-PICOSEC: Radiators and photocathodes

Photocathode:

Current technology: Cesium Iodide (CsI)

Pros:

- High quantum efficiency (QE) in vacuum ultraviolet (VUV) region which is most radiated by any radiator medium

Cons:

- Sensitivity to water \rightarrow performance rapidly deteriorates
- Ion bombardment (IBF) of CsI is challenging for high rate

We will investigate materials with similar level of QE:

Candidates are B4C, DLC and Nano diamond (ND)

- Goal is to achieve similar level of QE \rightarrow Extensive R&D
- Radiation hardness and unsensitivity to humid condition

Radiator:

Current technology: Magnesium Fluoride (MgF₂)

Pros:

- Transparency in vacuum ultraviolet (VUV) region which is most radiated by any radiator medium

Cons:

- Low photon yield
- large Cerenkov angle $\sin(\Theta_c) \rightarrow$ poor spatial information
- Smaller Θ_c material will result in even lower photon yield

We will investigate radiator materials for higher photon yield capability



Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)	Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)
Run272J	uRWELL7	250/440	uRWELL5	250/440	Run310J	uRWELL7	255/460	uRWELL5	255/460
Run275J	uRWELL7	250/450	uRWELL5	250/450	Run311J	uRWELL7	240/450	uRWELL5	240/450
Run276J	uRWELL7	250/460	uRWELL5	250/460	Run312J	uRWELL7	240/460	uRWELL5	240/460
Run277J	uRWELL7	255/440	uRWELL5	255/440	Run323J	uRWELL7	250/440	uRWELL5	250/440
Run278J	uRWELL7	255/450	uRWELL5	255/450	Run324J	uRWELL7	255/440	uRWELL5	255/440
Run279J	uRWELL7	255/460	uRWELL5	255/460	Run326J	uRWELL7	255/430	uRWELL5	255/430
Run286J	uRWELL7	260/440	uRWELL5	260/440	Run328J	uRWELL7	260/430	uRWELL5	260/430
Run289J	uRWELL7	260/450	uRWELL5	260/450	Run332J	uRWELL7	260/440	uRWELL5	260/440
Run293J	uRWELL7	260/430	uRWELL5	260/430	Run334J	uRWELL7	260/450	uRWELL5	260/450
Run305J	uRWELL7	250/460	uRWELL5	250/460	Run362J	uRWELL9	250/440	uRWELL11	250/440
Run307J	uRWELL7	255/450	uRWELL5	255/450	Run363J	uRWELL9	255/450	uRWELL11	255/450
Run309J	uRWELL7	250/450	uRWELL5	250/450	Run365J	uRWELL9	250/460	uRWELL11	250/460

Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)	Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)
Run366J	uRWELL9	250/440	uRWELL11	250/440	Run398J	uRWELL1	260/440	uRWELL3	260/440
Run367J	uRWELL9	255/450	uRWELL11	255/450	Run410J	uRWELL5	250/320	uRWELL9	250/320
Run369J	uRWELL9	255/460	uRWELL11	255/460	Run411J	uRWELL5	250/330	uRWELL9	250/330
Run371J	uRWELL9	260/450	uRWELL11	260/450	Run413J	uRWELL5	250/340	uRWELL9	250/340
Run372J	uRWELL9	260/440	uRWELL11	260/440	Run415J	uRWELL5	250/350	uRWELL9	250/350
Run382J	uRWELL1	250/440	uRWELL3	250/440	Run417J	uRWELL5	250/400	uRWELL9	250/400
Run384J	uRWELL1	250/450	uRWELL3	250/450	Run419J	uRWELL5	252/400	uRWELL9	252/400
Run386J	uRWELL1	250/430	uRWELL3	250/430	Run421J	uRWELL5	254/400	uRWELL9	254/400
Run390J	uRWELL1	255/430	uRWELL3	255/430	Run422J	uRWELL5	256/400	uRWELL9	256/400
Run392J	uRWELL1	255/440	uRWELL3	255/440	Run423J	uRWELL5	258/400	uRWELL9	258/400
Run394J	uRWELL1	255/450	uRWELL3	255/450	Run424J	uRWELL5	260/400	uRWELL9	260/400
Run396J	uRWELL1	260/430	uRWELL3	260/430	Run425J	uRWELL5	260/405	uRWELL9	260/405

Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)	Run no	Prototype 1	Anode/cat hode Voltage (V)	Prototype 2	Anode/cat hode Voltage (V)
Run426J	uRWELL5	260/410	uRWELL9	260/410	Run444J	uRWELL13	260/440	uRWELL9	260/390
Run427J	uRWELL5	255/410	uRWELL9	255/410	Run445J	uRWELL13	260/450	uRWELL9	260/388
Run428J	uRWELL5	250/410	uRWELL9	250/410					
Run429J	uRWELL5	250/340	uRWELL9	250/340					
Run431J	uRWELL5	255/405	uRWELL9	255/405					
Run436J	uRWELL13	250/440	uRWELL9	250/400					
Run437J	uRWELL13	250/450	uRWELL9	250/405					
Run438J	uRWELL13	250/460	uRWELL9	250/410					
Run439J	uRWELL13	255/440	uRWELL9	260/398					
Run441J	uRWELL13	255/450	uRWELL9	260/396					
Run442J	uRWELL13	255/460	uRWELL9	260/394					
Run443J	uRWELL13	260/430	uRWELL9	260/392					